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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/721,439		11/24/2003	Seyed Jafar Jafarian-Tehrani	LAM-P1028X	7139
49713	7590	03/15/2005		EXAMINER	
THELEN R	EID & F	PRIEST LLP	DINH, TRINH VO		
LAM P.O. BOX 64	40640		ART UNIT	PAPER NUMBER	
SAN JOSE,	SAN JOSE, CA 95164-0640				
				DATE MAILED: 03/15/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

9	Application No.	Applicant(s)	
SUPP	10/721,439	JAFARIAN-TEHRANI	I ET AL.
Notice of Allowability	Examiner	Art Unit	
	Trinh Vo Dinh	2821	
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED i or other appropriate comm GHTS. This application is	n this application. If not included unication will be mailed in due c	d ourse. THIS
1. \boxtimes This communication is responsive to <u>supplemental respons</u>	se filed 02/14/2005.		
2. The allowed claim(s) is/are 1-8 and 10-22.			
3. \square The drawings filed on $___$ are accepted by the Examiner	:		
 4. ☐ Acknowledgment is made of a claim for foreign priority una) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	been received. been received in Application	on No	on from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" on noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file ENT of this application.	e a reply complying with the requ	uirements
5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give			OTICE OF
 6. ☐ CORRECTED DRAWINGS (as "replacement sheets") mus (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the paper of the pap	on's Patent Drawing Reviews Amendment / Comment of the Market of the Header according to 37 Cl	r in the Office action of he drawings in the front (not the IFR 1.121(d).	
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT INFORMATION. 	SIT OF BIOLOGICAL MATERIAL FOR THE DEPOSIT OF BIOLOGICAL FOR THE DEPOSIT OF BIOLOGICA FOR THE DEPOSIT OF BIOL	ERIAL must be submitted. No OLOGICAL MATERIAL.	ote the
 Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☑ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 11/24/03.02/14/05 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material 	6. ☐ Interview S Paper No. 8), 7. ☐ Examiner's	nformal Patent Application (PTO- ummary (PTO-413), /Mail Date Amendment/Comment Statement of Reasons for Allow	

REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance:

The cited art of record fails to teach an apparatus and method for testing a plasma processing system comprising steps of measuring a first capacitance value between the bottom electrode and the grounded chamber at atmosphere, and a second capacitance value between the bottom electrode and the grounded chamber at vacuum, comparing said first and second capacitance values with first and second reference values to identify and determine any defects in the plasma processing system, said first and second reference values respectively representative of the capacitance of a defect-free chamber at atmosphere and the capacitance of a defect-free chamber including at least one installed consumable hardware part at vacuum as defined in claims 1, 10, 12 and 20-21. Therefore, claims 1-8 and 10-22 are presently allowed.

2. Any comments considered necessary by applicant must be submitted no latter than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Inquiry

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Trinh Vo Dinh whose telephone number is (571) 272-1821. The examiner can normally be reached on Monday to Friday from 9:30AM to 6:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Don Wong, can be reached on (571) 272-1834. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 10/721,439

Art Unit: 2821

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Trinh Vo Dinh

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March 07, 2005